

03500.103088

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
	:	Examiner: Not Yet Assigned
KOHEI OKAMOTO ET AL.)	
	:	Group Art Unit: Not Yet Assigned
Application No.: Not Yet Assigned)	
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Int'l Application No. PCT/JP2004/014809)	
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Filed: September 30, 2004)	
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For: PROCESS FOR PRODUCING)	
THREE-DIMENSIONAL	:	
STRUCTURE)	March 23, 2006

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Since the U.S. Patent and Trademark Office waived the requirement under 37 C.F.R. § 1.98 (a)(2)(i) for submitting a copy of each cited U.S. patent and each U.S. patent application publication for all U.S. national patent applications and for all international applications that have entered the national stage under 35 U.S.C. § 371, no copies of such documents are enclosed. Copies of the other listed documents are enclosed.

This Information Disclosure Statement is, in part, to make of record documents cited in the International Search Report and the Written Opinion issued in the


international application of which the subject application is a national stage. Copies of the Search Report and the Written Opinion are enclosed.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,



Jason M. Okun
Attorney for Applicants
Registration No.: 48,512

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200

FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)				ATTY DOCKET NO. 03500.103088		APPLICATION NO. N.Y.A. Nat'l Stage of PCT/JP2004/014809	
				APPLICANT Kohei Okamoto et al.			
				FILING DATE September 30, 2004		GROUP N.Y.A.	

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		6,456,416 B1	09/24/02	Ichimura et al.	359	241	
		2002/0070352 A1	06/13/02	Allan et al.	250	492.1	
		2004/0027675 A1	02/12/04	Wu et al.	359	619	

FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
	EP	1 089 095 A2	04/04/01	Europe			
	WO	02/084340 A1	10/24/02	International			

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)	
	Satoru Shoji et al., "Photofabrication of a Photonic Crystal Using Interference of UV Laser," <u>Proceedings of the SPIE</u>, vol. 3470, pp. 514-44 (June 1999).
	Mike Hutley et al., "Microlens Array," <u>Physics World</u>, pp. 27-32 (July 1991).
	V. Mizeikis et al., "Femtosecond Laser Microfabrication of Photonic Crystal Structures by Glass Damaging and Resin Photosolidification," <u>Proceedings of the 4th Pacific Rim Conference on Lasers and Electro-Optics</u>, vol. 1, pp. I-302 - I-303 (2001).
	Dongmin Wu et al., "Fabrication and Characterization of THz Plasmonic Filter," <u>Proceedings of the 2002 2nd IEEE Conference on Nanotechnology</u>, pp. 229-31 (August 2002).

EXAMINER	DATE CONSIDERED
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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